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Supplementary information

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2 The Flexible Pressure Sensor based on MXene-Textile Network Structure

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- 5 ¹Tongkuai Li and Longlong Chen contributed equally
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- 8 Fig. S1. The MXene uniformly adhered to each individual cotton textile fiber. (scale bar, 1 μ m). (b) Mxene (scale bar, 200 9 nm).
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Fig. S2. The $\Delta I/I0$ profiles after repeating 6,500 cycles shows a degradation by 20%

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16 Fig. S3. Real-time monitoring of current changes upon wrist pulses before and after exercise, showing that the tester's pulse rate

17 was 72 times/min and 90 times/min, respectively.



Fig. S4. The statistical sensitivity graph of our pressure sensor. (a) in the pressure region under 29 kPa, (b) in thepressure region of 29–40 kPa.

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Table S1 Performance summary of representative flexible pressure sensors

| Materials/Structures | Device type | Sensitivity | Response time | References |
|--|----------------|---|---|------------|
| Gaussian random distribution contact surface profile | Piezoresistive | 0 - 14 kPa, 13.8 kPa ⁻¹ | 23 ms | 1 |
| CNT-cotton textile | Piezoresistive | <3.5kPa, 14.4 kPa ⁻¹ 3.5 – 15 kPa, 7.8 kPa ⁻¹ | ≈24 ms | 2 |
| archical Gr/PDMS | Piezoresistive | 0 - 12 kPa, 8.5 kPa ⁻¹ | ≈40 ms | 3 |
| Replication from banana leaf | Piezoresistive | <400 Pa, 10 kPa ⁻¹ 400 – 1000 Pa, 4.3 kPa ⁻¹ | response time 36 ms relaxation time 30 ms | 4 |
| SWNT/tissue paper | Piezoresistive | 35–2500 Pa, 2.2 kPa ⁻¹ 2500 –11 700 Pa, 1.3 kPa ⁻¹ | 35 ms | 5 |
| Graphene-silk network structure | Piezoresistive | <140kPa, 0.4 kPa ⁻¹ | - | 6 |
| MXene-Textile Network | Piezoresistive | <29 kPa, 3.844 kPa ⁻¹ 29–40 kPa, 12.095 kPa ⁻¹ | response time ≈26 ms recovery times ≈50 ms | This work |

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